

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Application Serial No
Confirmation No None
Filing Date January 5, 2001
Inventor Leonard Forbes, et al.
Assignee Micron Technology, Inc.
Group Art Unit
Examiner Nguyen, K.D.
Attorney's Docket No
Customer No
Title: Methods of Forming Capacitor Structures, and Capacitor Structures

## SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

References -See Attached Form PTO-1449

The Examiner's attention is directed to the references which are listed on the attached Form PTO-1449, copies of which are attached. No admission is made regarding whether all the submitted references are prior art.

Citation of the referenced art is respectfully requested.

Respectfully\_submitted,

Hyta

Reg. No. 46,791

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OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)										
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